IN THE CLAIMS

Previous claims 27-43 have been renumbered by the Examiner as 29-45.

Claims 43-45 have been withdrawn by the Examiner.

Please amend the following claims which are pending in the present application:

What is claimed:

1-28. (Cancelled)

29. (Currently amended) A method comprising:

heating a thermal dissipation device to an elevated temperature;

exposing the thermal dissipation device to a first medium to lower the

temperature of the thermal dissipation device to an intermediate temperature;

after the intermediate temperature is maintained throughout the thermal

dissipation device, exposing the thermal dissipation device to a second medium to

lower the temperature of the thermal dissipation device to a cryogenic temperature,

the cryogenic temperature being below the intermediate temperature;

bringing the temperature of the thermal dissipation device up to an ambient

temperature; and

thermally connecting the thermal dissipation device to a microelectronic

device to dissipate heat generated within the microelectronic device.

Examiner: Ip, Sikyin Art Unit: 1742 30. (Currently Amended) The method of claim 27 29, wherein said heating changes

a microstructure of a material of the thermal dissipation device from a fine grain

structure to a coarse grain structure, the fine grain structure corresponding to a first

thermal conductivity, the coarse grain structure corresponding to a second thermal

conductivity, the second thermal conductivity being greater than the first thermal

conductivity, the microstructure of the material maintaining the coarse grain

structure after the temperature of the thermal dissipation device is brought up to the

ambient temperature.

31. (Currently Amended) The method of claim 28 30, wherein the material is a

metal.

32. (Currently Amended) The method of claim 29, 31 wherein the metal is at least

one of aluminum and copper.

33. (Currently Amended) The method of claim 30, 32 wherein the thermal

dissipation device is a heat sink.

34. Currently Amended) The method of claim 31 33 wherein the microelectronic

device is a microelectronic die mounted to a package substrate.

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35. (Currently Amended) The method of claim 32, 34 wherein the intermediate

temperature is approximately -100 degrees Fahrenheit.

36. (Currently Amended) The method of claim 33, 35 wherein the cryogenic

temperature is approximately -327 degrees Fahrenheit.

37. (Currently Amended) The method of claim 34, 36 wherein the first medium is

air directly over a container containing a bath of a cryogenic material.

38. (Currently Amended) The method of claim 35, 37 wherein the second medium

is the bath of cryogenic material.

39. (Currently Amended) The method of claim 36, 38 wherein the cryogenic

material is liquid nitrogen.

40. (Currently amended) A method comprising:

changing a microstructure of a material of a thermal dissipation device from

having a first number of grain boundaries to having a second number of grain

boundaries by heating the material to an elevated temperature, the first number of

grain boundaries corresponding to a first thermal conductivity, the second number

of grain boundaries corresponding to a second thermal conductivity, the second

thermal conductivity being higher than the first thermal conductivity;

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lowering the temperature of the material to an intermediate temperature at a

first rate;

after the intermediate temperature is maintained throughout the material,

lowering the temperature of the material to a cryogenic temperature at a second

rate, the cryogenic temperature being below the intermediate temperature;

bringing the temperature of the material up to an ambient temperature, the

microstructure of the material maintaining the second number of grain boundaries;

and

thermally connecting the thermal dissipation device to microelectronic device

to dissipate heat generated within the microelectronic device;

41. (Currently Amended) The method of claim 38, 40 wherein the second rate is

higher than the first rate.

42. (Currently Amended) The method of claim 38, 41 wherein the thermal

dissipation device is a heat sink, the material is metal, and the microelectronic device

is a microelectronic die mounted to a package substrate.

43. (Withdrawn) A microelectronic package comprising:

a package substrate;

a microelectronic die mounted to the package substrate; and

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a thermal dissipation device thermally connected to the microelectronic die to dissipate heat generated within the microelectronic die, the thermal dissipation device made by a process comprising:

heating the thermal dissipation device to change a microstructure of a material thereof by reducing the number of grain boundaries from a first number of grain boundaries to a second number of grain boundaries, the first number of grain boundaries corresponding to a first thermal conductivity, the second number of grain boundaries corresponding to a second thermal conductivity, the second thermal conductivity being greater than the first;

exposing the thermal dissipation device to a first medium to bring the temperature of the thermal dissipation device to an intermediate temperature;

exposing the thermal dissipation device to a second medium to bring the temperature of the thermal dissipation device to a cryogenic temperature, the cryogenic temperature being below the intermediate temperature; and

bringing the temperature of the thermal dissipation device up to an ambient temperature, the microstructure of the material of the thermal dissipation device maintaining the second number of grain boundaries.

44. (Withdrawn) The microelectronic package of claim 41, wherein the material is a metal alloy having precipitating constituents.

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45. (Withdrawn) The microelectronic package of claim 42, wherein the material is aluminum alloy T6061.

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